

L Number	Hits	Search Text	DB	Time stamp
-	52	((("4855247") or ("5217912") or ("5408115") or ("5654212") or ("5707901") or ("5714413") or ("5783475") or ("5783478") or ("5789298") or ("5814553") or ("5840603") or ("5846857") or ("5851890") or ("5882973") or ("5895246") or ("5899722") or ("5908315") or ("5972760") or ("6004852") or ("6010935") or ("6018180") or ("6074922") or ("6114734") or ("6127711") or ("6133105") or ("6140192") or ("6153483") or ("6156593") or ("6165857") or ("6180475") or ("6200840") or ("6235606") or ("6245620") or ("6251719") or ("6251764") or ("6255152") or ("6291354") or ("6297112") or ("6316304") or ("6329225") or ("6335249") or ("6335279") or ("6355966") or ("6391732") or ("6395598") or ("6406987") or ("6432784") or ("6440875") or ("6448167") or ("6472700") or ("6498067") or ("6586332")).PN.	USPAT; US-PGPUB	2004/08/07 21:31
-	38	(spacer\$1 near side\$1wall\$1) with under\$1cut	USPAT; US-PGPUB	2004/08/07 21:37
-	2615	(spacer\$1 near side\$1wall\$1) same nitride same oxide	USPAT; US-PGPUB	2004/08/07 21:38
-	6	((spacer\$1 near side\$1wall\$1) same nitride same oxide) and (ethylene adj glycol)	USPAT; US-PGPUB	2004/08/07 21:42
-	177	(ethylene adj glycol) with ((hydrofluoric adj acid) HF)	USPAT; US-PGPUB	2004/08/07 21:43
-	181	((ethylene adj glycol) with ((hydrofluoric adj acid) HF)) HFEG	USPAT; US-PGPUB	2004/08/07 22:35
-	1543	selectiv\$2 adj epitaxial\$2 adj grow\$2	USPAT; US-PGPUB	2004/08/07 22:36
-	4435	(selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG	USPAT; US-PGPUB	2004/08/07 22:36
-	138	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and (clean\$5 with surface with substrate)	USPAT; US-PGPUB	2004/08/07 22:38
-	0	((((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and (clean\$5 with surface with substrate)) and (clean\$5 with surface with substrate with (HFEG ethylene\$1glycol)))	USPAT; US-PGPUB	2004/08/07 22:37
-	25	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) same (clean\$5 with surface with substrate)	USPAT; US-PGPUB	2004/08/07 22:43
-	133	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and ((side\$1wall\$1 spacer\$1) same (silicon adj nitride) same (silicon adj oxide))	USPAT; US-PGPUB	2004/08/07 23:01
-	0	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and DHF and HFEG	USPAT; US-PGPUB	2004/08/07 23:02
-	15	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and DHF	USPAT; US-PGPUB	2004/08/07 23:06
-	97	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and under\$1cut	USPAT; US-PGPUB	2004/08/07 23:07
-	29	"4269654"	USPAT; US-PGPUB	2004/08/07 23:25
-	860	selectiv\$2 adj epitax\$7 adj grow\$5	EPO; JPO; DERWENT; IBM_TDB	2004/08/07 23:26
-	0	(selectiv\$2 adj epitax\$7 adj grow\$5) and (HPEG ethylene\$1glycol)	EPO; JPO; DERWENT; IBM_TDB	2004/08/07 23:27
-	38	(selectiv\$2 adj epitax\$7 adj grow\$5) and clean\$5	EPO; JPO; DERWENT; IBM_TDB	2004/08/07 23:32
-	1	2001-518938.NRAN.	DERWENT	2004/08/07 23:31
-	38	((selectiv\$2 adj epitaxial\$2 adj grow\$2) or SEG) and pre\$1clean\$5	USPAT; US-PGPUB	2004/08/07 23:32
-	463	438/300.ccls.	USPAT; US-PGPUB	2004/08/07 23:55
-	1061	438/303.ccls. not (438/333.ccls.)	USPAT; US-PGPUB	2004/08/08 00:16

-	479	438/595.ccls. not (438/303.ccls. 438/333.ccls.)	USPAT; US-PGPUB	2004/08/08 00:25
-	524	(438/749.ccls. 438/756.ccls. 438/757.ccls.) not (438/595.ccls. 438/303.ccls. 438/333.ccls.)	USPAT; US-PGPUB	2004/08/08 00:33
-	6916	(side\$1wall\$1 spacer\$1) with nitride with oxide	USPAT; US-PGPUB	2004/08/08 00:34
-	72	((side\$1wall\$1 spacer\$1) with nitride with oxide) and (etch\$5 with under\$1cut\$5 with (prevent\$5 avoid\$5))	USPAT; US-PGPUB	2004/08/08 00:35
-	93	(dhf (dilute\$1 adj hydrofluoric adj acid)) and (HFEG (ethylene adj glycol))	USPAT	2004/08/08 00:53
-	124	(dhf (dilute\$1 adj hydrofluoric adj acid)) and (HFEG (ethylene adj glycol))	USPAT; US-PGPUB	2004/08/08 01:11
-	148	438/300.ccls. and ((side\$1wall\$1 spacer\$1) with oxide with nitride)	USPAT; US-PGPUB	2004/08/08 01:12